

Supplementary Materials: The Effect of Charged Ag Nanoparticles on Thin Film Growth during DC Magnetron Sputtering

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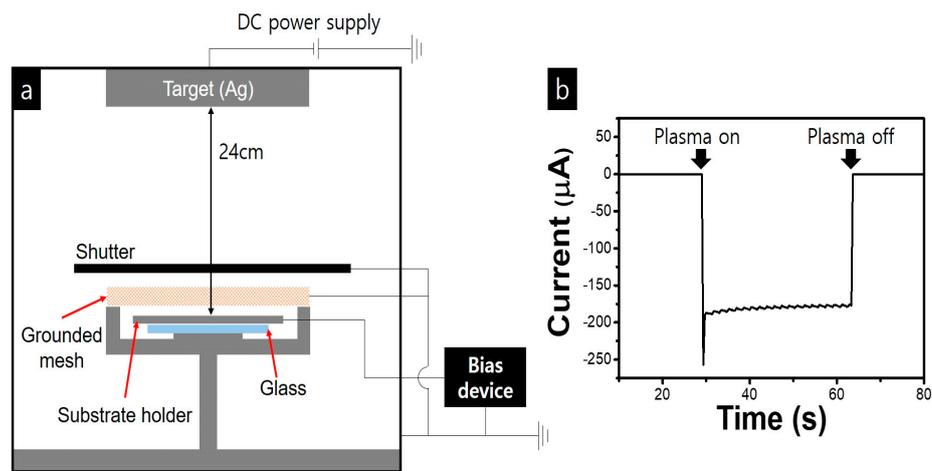


Figure S1. Gaussian graphs for the size distribution of Ag nanoparticles under each capture condition.

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